**OLED Components**

- **Metal**
- **ETL and EIL**
- **EML**
- **HTL**
- **HIL**
- **ITO**
- **Glass or Film**

- **Hole Injection Layer**: HIL-1; HIL-2
- **Hole Transport Layer**: HTL-2; HTL-3
- **Emissive Layer**: EM-1; EM-2
- **Dopant**: RD-1(Ph); RD-2(Ph); GD-1(Ph); BD-2
- **Electron Transport Layer**: ETL-2; ETL-3; ETL-4

**Manufacturing Facility**

1. TFT G3.5 array production line
2. 200mm X 200mm Sunic evaporation system
3. IVL measurement system
4. lifetime measurement system
5. 4” sublimation machine
6. 20L, 50L, 200L jacketed glass reactor
7. HPLC, TGA, DSC
8. UVL and PL